Record Nr. UNINA9910830498003321 Advances in electrochemical science and engineering. Volume 3 **Titolo** [[electronic resource] /] / edited by Heinz Gerischer and Charles W. Tobias; contributions from W.P. Gomes ... [et al.] Weinheim [Germany], : VCH, 1994 Pubbl/distr/stampa **ISBN** 1-281-84296-6 9786611842963 3-527-61677-2 3-527-61686-1 Descrizione fisica 1 online resource (343 p.) Collana Advances in electrochemical science and engineering, , 0938-5193;; v. 3 Altri autori (Persone) GerischerHeinz TobiasCharles W. <1920-1996.> GomesW. P Disciplina 541.3/7 541.37 Soggetti Electrochemistry Lingua di pubblicazione Inglese Materiale a stampa **Formato** Livello bibliografico Monografia Note generali Description based upon print version of record. Nota di bibliografia Includes bibliographical references and index. Advances in Electrochemical Science and Engineering; Contents: Nota di contenuto Electrochemistry of III-V Compound Semiconductors: Dissolution Kinetics and Etching; Electroless Deposition Processes: Fundamentals and Applications: Current Distribution and Shape Change in Electrodeposition of Thin Films for Microelectronic Fabrication.; The Principles and Techniques of Electrolytic Aluminum Deposition and Dissolution in Organoaluminum Electrolytes; Magnetically Soft Materials in Data Storage: Their Properties and Electrochemistry; Index Like its predecessors, volume three of this meanwhile well-established Sommario/riassunto series covers selected topics from electrochemical science and its applications. The authors have been carefully selected among the leaders in the respective fields. Their authoritative and comprehensive

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